

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/506,384	03/02/2005	Sang-Hea Shim	1455-050676	1698
28289 75	90 06/23/2006		EXAMINER	
THE WEBB LAW FIRM, P.C.			CONLEY, SEAN EVERETT	
700 KOPPERS 436 SEVENTH			ART UNIT	PAPER NUMBER
PITTSBURGH,	, PA 15219		1744	
			DATE MAILED: 06/23/2006	5

Please find below and/or attached an Office communication concerning this application or proceeding.

				/		
		Application No.	Applicant(s)			
Office Action Summary		10/506,384	SHIM ET AL.			
		Examiner	Art Unit			
		Sean E. Conley	1744			
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet w	ith the correspondence addres	S		
WHI(- Exte after - If NO - Failt Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DATE of time may be available under the provisions of 37 CFR 1.15 SIX (6) MONTHS from the mailing date of this communication. Depriod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNI 36(a). In no event, however, may a will apply and will expire SIX (6) MOI c, cause the application to become A	CATION. reply be timely filed NTHS from the mailing date of this commur BANDONED (35 U.S.C. § 133).			
Status						
1)⊠	Responsive to communication(s) filed on 19 A	<i>pril 2006</i> .				
2a) <u></u> ☐	This action is FINAL. 2b)⊠ This action is non-final.					
3)	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.E	D. 11, 453 O.G. 213.			
Disposit	ion of Claims					
4)🖂	Claim(s) 1-23 is/are pending in the application.					
	4a) Of the above claim(s) 1-19 is/are withdrawr	n from consideration.				
5)	Claim(s) is/are allowed.					
6)⊠	Claim(s) 20-23 is/are rejected.					
7)	Claim(s) is/are objected to.					
8)[Claim(s) are subject to restriction and/o	r election requirement.				
Applicat	ion Papers					
9)[The specification is objected to by the Examine	er.				
10)	The drawing(s) filed on is/are: a) ☐ according according to a cordinate of the drawing according to a cordinate of the drawing (s) filed on is/are: a) ☐ according to a cordinate of the drawing (s) filed on is/are: a) ☐ according to a cordinate of the drawing (s) filed on is/are: a) ☐ accordinate of the drawing (s) filed on	epted or b) Objected to	by the Examiner.			
	Applicant may not request that any objection to the	drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).			
	Replacement drawing sheet(s) including the correct	tion is required if the drawing	y(s) is objected to. See 37 CFR 1.	.121(d).		
11)	The oath or declaration is objected to by the Ex	caminer. Note the attache	d Office Action or form PTO-1	52.		
Priority (under 35 U.S.C. § 119					
-	Acknowledgment is made of a claim for foreign All b) Some * c) None of: Certified copies of the priority documents	s have been received.				
	2. Certified copies of the priority documents		· · · — —			
	3. Copies of the certified copies of the prior application from the International Bureau	•	received in this National Stag	je		
* (See the attached detailed Office action for a list		received.			
Attachmen	at(s)					
	ce of References Cited (PTO-892)		Summary (PTO-413)			
3) Infor	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date		(s)/Mail Date Informal Patent Application (PTO-152))		

Application/Control Number: 10/506,384 Page 2

Art Unit: 1744

DETAILED ACTION

Response to Amendment

1. The amendment filed April 19, 2006 has been received and considered for examination. Claims 1-23 are pending with claims 1-19 withdrawn from consideration as being directed to a non-elected invention.

Claim Objections

2. Claim 21 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Claim 21 includes the limitation that the stabilized hypochlorite and the bromide ion source is added to a habitat of microorganisms up to 0.1 to 10 ppm total halogen residual. This limitation is found in step (c) of claim 20. Therefore, claim 21 does not further limit the method of claim 20.

Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. A nonstatutory obviousness-type double patenting rejection is appropriate where the conflicting claims are not identical, but at least one examined application claim is not patentably distinct from the reference claim(s) because the examined application claim is either anticipated by, or would have been obvious over, the reference claim(s). See, e.g., *In re Berg*, 140

Art Unit: 1744

F.3d 1428, 46 USPQ2d 1226 (Fed. Cir. 1998); *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) or 1.321(d) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent either is shown to be commonly owned with this application, or claims an invention made as a result of activities undertaken within the scope of a joint research agreement.

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

3. Claims 20-23 are rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claims 13, 15 and 18 of U.S. Patent No. 6,478,972 B1 in view of Rutkiewic (U.S. Patent No. 3,767,586) and Steinhauer (U.S. Patent No. 4,071,463).

Claims 13, 15 and 18 of U.S. Patent No. 6,478,972 discloses all of the limitations of claims 20-23 except for specifically indicating that the stabilized alkali or alkaline earth metal hypochlorite has a pH of at least 11.

Rutkiewic discloses a process for preparing stable aqueous solutions of N-halo compounds. Specifically, Rutkiewic discloses that it is known to combine a stabilizer such as sulfamic acid with an alkali or alkaline earth metal hypochlorite. However, these solutions do not produce stabilized concentrated solutions. In order to overcome this deficiency, Rutkiewic has determined that the pH of the hypochlorite solution must be controlled. Without pH control a concentrated hypochlorite solution will decompose rapidly upon standing (see col. 1, lines 40-55).

Application/Control Number: 10/506,384 Page 4

Art Unit: 1744

Steinhauer discloses a stable aqueous cleaning formulation that comprises sodium hypochlorite. In order to maintain maximum hypochlorite stability the formulation is maintained at a high pH, preferably from about 11.0 to 13.0. This is achieved by including a water soluble alkaline builder or a suitable base such as sodium hydroxide into the composition (see col. 2, lines 35-48). This reference has been relied upon to teach an example of a formulation comprising sodium hypochlorite and having a pH of about 11.0-13.0 in order to maximize stability.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the process of claims 13, 15 and 18 of U.S. Patent No. 3,767,586. and include a suitable base such as sodium hydroxide in the stabilizer formulation as taught by Steinhauer in order to raise the pH to a level of about 11.0 to 13.0 which further increases the stability of the sodium hypochlorite and also prevents rapid decomposition of the solution as taught by Rutkiewic.

Claim Rejections - 35 USC § 103

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

4. Claims 20-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shim et al. (U.S. Patent No. 6,478,972 B1) in view of Dallmier et al. (U.S. Patent No. 5,942,126) and Steinhauer (U.S. Patent No. 4,071,463).

Application/Control Number: 10/506,384

Art Unit: 1744

Regarding claim 20, Shim et al. discloses a method of controlling the growth of microorganisms, comprising the steps of: (a) preparing stabilized alkali or alkaline earth metal hypochlorite by mixing a chlorine oxidant including alkali or alkaline earth metal hypochlorite with a stabilizer selected from the group consisting of acid amide derivatives of carbonic acids, carboxylic acids, amino acids, and sulfuric acids; (b) preparing a bromide ion source; and (c) sequentially or simultaneously introducing the stabilized alkali or alkaline earth metal hypochlorite prepared in step (a) and the bromide ion source prepared in step (b) into a habitat of microorganisms up to 0.1 to 10 ppm total halogen residual (see col. 3, line 61 to col. 4, line 15). Shim et al. fails to specifically teach the step of preparing a stabilized alkaline earth metal hypochlorite having a pH of at least 11. Shim et al. does however disclose that sodium hypochlorite (NaOCI), which is an alkali or alkaline earth metal hypochlorite, is an example of a hypochlorite widely used to control microbial fouling in various types of aqueous systems including cooling water towers and swimming pools.

Dallmier et al. discloses several methods well known in the art that are used to stabilize NaOCI. One way to stabilize NaOCI is to include a stabilizer such as an acid as taught by Shim et al. above and also disclosed by Dallmier et al (see col. 1, lines 35-37). Furthermore, Dallmier et al. discloses that the process has been further improved upon by controlling the pH of the solution which further increases the stability of concentrated solutions of sodium hypochlorite (see col. 1, lines 27-40).

Steinhauer discloses a stable aqueous cleaning formulation that comprises sodium hypochlorite. In order to maintain maximum hypochlorite stability the

Art Unit: 1744

formulation is maintained at a high pH, preferably from about 11.0 to 13.0. This is achieved by including a water soluble alkaline builder or a suitable base such as sodium hydroxide into the composition (see col. 2, lines 35-48). This reference has been relied upon to teach an example of a formulation comprising sodium hypochlorite and having a pH of about 11.0-13.0 in order to maximize stability.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the process of Shim et al. and include a suitable base such as sodium hydroxide in the stabilizer formulation as taught by Steinhauer in order to raise the pH to a level of about 11.0 to 13.0 which increases the stability of the sodium hydroxide to a maximum level as taught by Dallmier et al.

Regarding claims 21 and 22, Shim et al. discloses that the stabilized hypochlorite and the bromide ion source is added to a habitat of microorganisms up to 0.1 to 10 ppm total halogen residual (see col. 4, lines 5-15).

Regarding claim 23, Shim et al. discloses that the water system is selected from the group consisting of swimming pools, spas, cooling water towers, bleaching agents, recycling water systems, and water slides (see col. 8, lines 45-53).

5. Claims 20-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shim et al. (U.S. Patent No. 6,478,972 B1) in view of Rutkiewic (U.S. Patent No. 3,767,586) and Steinhauer (U.S. Patent No. 4,071,463).

Application/Control Number: 10/506,384 Page 7

Art Unit: 1744

Regarding claim 20, Shim et al. discloses a method of controlling the growth of microorganisms, comprising the steps of: (a) preparing stabilized alkali or alkaline earth metal hypochlorite by mixing a chlorine oxidant including alkali or alkaline earth metal hypochlorite with a stabilizer selected from the group consisting of acid amide derivatives of carbonic acids, carboxylic acids, amino acids, and sulfuric acids; (b) preparing a bromide ion source; and (c) sequentially or simultaneously introducing the stabilized alkali or alkaline earth metal hypochlorite prepared in step (a) and the bromide ion source prepared in step (b) into a habitat of microorganisms up to 0.1 to 10 ppm total halogen residual (see col. 3, line 61 to col. 4, line 15). Shim et al. fails to specifically teach the step of preparing a stabilized alkaline earth metal hypochlorite having a pH of at least 11. Shim et al. does however disclose that sodium hypochlorite (NaOCI), which is an alkali or alkaline earth metal hypochlorite, is an example of a hypochlorite widely used to control microbial fouling in various types of aqueous systems including cooling water towers and swimming pools.

Rutkiewic discloses a process for preparing stable aqueous solutions of N-halo compounds. Specifically, Rutkiewic discloses that it is known to combine a stabilizer such as sulfamic acid with an alkali or alkaline earth metal hypochlorite. However, these solutions do not produce stabilized concentrated solutions. In order to overcome this deficiency, Rutkiewic has determined that the pH of the hypochlorite solution must be controlled. Without pH control a concentrated hypochlorite solution will decompose rapidly upon standing (see col. 1, lines 40-55).

Application/Control Number: 10/506,384

Page 8

Art Unit: 1744

Steinhauer discloses a stable aqueous cleaning formulation that comprises sodium hypochlorite. In order to maintain maximum hypochlorite stability the formulation is maintained at a high pH, preferably from about 11.0 to 13.0. This is achieved by including a water soluble alkaline builder or a suitable base such as sodium hydroxide into the composition (see col. 2, lines 35-48). This reference has been relied upon to teach an example of a formulation comprising sodium hypochlorite and having a pH of about 11.0-13.0 in order to maximize stability.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the process of Shim et al. and include a suitable base such as sodium hydroxide in the stabilizer formulation as taught by Steinhauer in order to raise the pH to a level of about 11.0 to 13.0 which further increases the stability of the sodium hypochlorite and also prevents rapid decomposition of the solution as taught by Rutkiewic.

Regarding claims 21 and 22, Shim et al. discloses that the stabilized hypochlorite and the bromide ion source is added to a habitat of microorganisms up to 0.1 to 10 ppm total halogen residual (see col. 4, lines 5-15).

Regarding claim 23, Shim et al. discloses that the water system is selected from the group consisting of swimming pools, spas, cooling water towers, bleaching agents, recycling water systems, and water slides (see col. 8, lines 45-53).

Response to Arguments

6. Applicant's arguments, see pages 2-3, filed April 19, 2006, with respect to the rejection(s) of claim(s) 20-23 under 35 U.S.C. 103(a) have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Shim (6,478,972), Rutkiewic (3,767,586), Steinhauer (4,071,463), and Dallmier et al. (5,942,126).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sean E. Conley whose telephone number is 571-272-8414. The examiner can normally be reached on M-F 8:30-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gladys Corcoran can be reached on 571-272-1214. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SEC X.E.C.

June 16, 2006

KRISANNE JASTRZAB PRIMARY EXAMINER